IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: M. OOE, et al.

Serial No.: 10/585,738

Filed: JULY 12, 2006

For: PHOTOSENSITIVE POLYMER COMPOSITION, METHOD OF

PRODUCING PATTERN AND ELECTRONIC PARTS

Group AU: 1785

Examiner: Gerard T. Higgins

Confirm. No.: 7230

SUPPLEMENTAL RESPONSE

Commissioner for Patents December 15, 2011

P.O. Box 1450

Alexandria, Virginia 22313-1450

Sir:

This Supplemental Response is supplemental to the Amendment and Submission Under 37 C.F.R. §1.114 filed October 14, 2011, which was filed in response to the Office Action mailed April 14, 2011. October 14, 2011.

Applicants request entry and consideration of the attached Declaration Under 37 C.F.R. 1.132. Applicants also request that the suspension of action requested in the Request for Continued Examination (RCE) filed Octber 14, 2011 be lifted and that the Examiner act on the application on the basis of the Amendment and Submission Under 37 C.F.R. §1.114 filed October 14, 2011, the following remarks and the attached Declaration Under 37 C.F.R. 1.132.

During the interview with Examiners Higgins and Ruthkosky on August 2, 2011, the first named inventor, Masayuki Ooe, presented a table containing sensitivity values for Example 1 of the above-identified application, Comparative Example 4. Tadayuki '268 and Tadayuki '063. In that table, the sensitivity values for